Amendments to the Claims

This listing of the Claims will replace all prior versions and listings of the claims in this patent application.

Listing of the Claims

1-15. (canceled)

16. (currently amended) A silane abatement process comprising:

bubbling flowing N_2 gas at high pressure to bubble waste silane gas into a water-filled chamber;

reacting said waste silane gas with oxygen dissolved in water in said water-filled chamber whereby SiO₂ precipitates are formed and wherein said SiO₂ precipitates settle to a bottom surface of said water-filled chamber; and

draining said SiO₂ precipitates out of said water-filled chamber.

17. (currently amended) The process according to Claim 16 further comprising flowing N₂ gas atwherein said high pressure to push said waste silane gas into said water-filled chamber is about 100 psi.

18-25. (canceled)

26. (previously presented) The process according to Claim 16 wherein said reacting of said waste silane gas with said oxygen occurs under said water in said water-filled chamber.

27. (currently amended) A silane abatement process consisting of:

bubbling flowing N_2 gas at high pressure to push waste silane gas into a water-filled chamber wherein said waste silane gas enters said chamber under the water;

reacting said waste silane gas with oxygen dissolved in said water in said water-filled chamber whereby SiO₂ precipitates are formed and wherein said SiO₂ precipitates settle to a bottom surface of said water-filled chamber; and

draining said SiO₂ precipitates out of said water-filled chamber.

28. (canceled)

- 29. (currently amended) The process according to Claim 28-27 wherein said high pressure is about 100 psi.
- 30. (currently amended) A silane abatement process consisting of: providing waste silane gas from a manufacturing process;

without first applying a combustion process, bubbling flowing N_2 gas at high pressure to push waste silane gas into a water-filled chamber wherein said waste silane gas enters said chamber under the water;

supplying a continuous fresh air intake into said water-filled chamber;

reacting said waste silane gas with oxygen dissolved in said water in said water-filled chamber whereby SiO₂ precipitates are formed and wherein said SiO₂ precipitates settle to a bottom surface of said water-filled chamber; and

draining said SiO₂ precipitates out of said water-filled chamber.

- 31. (canceled)
- 32. (currently amended) The process according to Claim 31-30 wherein said high pressure is about 100 psi.
- 33. (canceled)